



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Rengarajan et al.
Serial No.: 09/000,626
Filed: December 30, 1997
Entitled: Recessed Shallow Trench Isolation Structure Nitride
Liner and Method of Making Same

Group Art Unit: 2811

Examiner: T. TRAN

Docket No.: 97 P 6971 US 02

Batch No.: TBD

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LETTER TO OFFICIAL DRAFTSMAN


Attention: Drawing Processing Branch
Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

Pursuant to M.P.E.P. Section 608.02, enclosed please find six (6) sheets of formal drawings in the referenced case. These are formal versions of the informal drawings filed with the application.

If there are any informalities with these drawings, Applicant requests issuance of a Form PTO-948 identifying the informalities noted by the Official Draftsman.

Respectfully submitted,


Stanton C. Braden
Reg. No. 32,556

Date: December 3, 2001

Infineon Technologies North America Corp.
c/o Siemens Corporation
Intellectual Property Department
186 Wood Avenue South
Iselin, NJ 08830
(732) 321-3015
SCB/vl

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CERTIFICATE OF MAILING PURSUANT TO 37 CFR § 1.8

I hereby certify that this correspondence is being deposited on or before the date, December 3, 2001 with the United States Postal Service with sufficient postage as first class mail in an envelope addressed Assistant Commissioner for Patents, Washington, D.C. 20231

Date of Signature: December 3, 2001


Pamela J. Gewirtz